

Contents

CONTRIBUTORS TO VOLUME 12	vii
PREFACE	ix
ARTICLES PLANNED FOR FUTURE VOLUMES	xi
CONTENTS OF PREVIOUS VOLUMES	xiii

Reflectance and Preparation of Front Surface Mirrors for Use at Various Angles of Incidence from the Ultraviolet to the Far Infrared

G. Hass, J. B. Heaney, and W. R. Hunter

I. Introduction	2
II. Reflectance Measurements and Preparation of Mirror Coatings	3
III. Reflectance of Metallic Front Surface Mirrors without Overcoating	16
IV. Mirror Coatings with Protective Layers and Reflectance-Enhancing Surface Films	22
V. Metal-Dielectric Mirrors for Use as Reflection-Type Filters	42
VI. Water Absorption in Evaporated Dielectric Films	46
References	49

Photoemissive Materials

C. Ghosh

I. Introduction	54
II. The Mechanism of Photoemission	54
III. The Ag-O-Cs (S-1) Photocathode	70
IV. The Alkali Antimonides	84
V. Negative Electron Affinity Materials	112
VI. Applications of Photoemissive Materials	140
VII. Conclusions	157
References	158

Chemical Solution Deposition of Inorganic Films

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and A. P. Thakoor*

I. Introduction	168
II. Spray Pyrolytic Process	169
III. Characteristic Features of the Spray Pyrolytic Process	178

IV. Multicomponent Doping and Alloying Effects	181
V. Structural Properties	187
VI. Electrical and Optical Properties	192
VII. Solution Growth Process	201
VIII. Impurity and Dopant Effects	211
IX. Multicomponent Films	212
X. Oxide Films	213
XI. Structure	214
XII. Transport Properties	217
XIII. Some Large-Area Application	223
XIV. Concluding Remarks	230
References	232

Plasma-Enhanced Chemical Vapor Deposition of Thin Films

S. M. Ojha

I. Introduction	237
II. Deposition Techniques and Systems	238
III. Preparation and Properties of Films	246
IV. Plasma Oxidation	275
V. Plasma Carburizing	283
VI. Glow-Discharge Nitriding	286
VII. Conclusions	289
References	289
 AUTHOR INDEX	297
SUBJECT INDEX	312